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Issue Date: 10/28/02

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User ID: ginab

Page 1  
KS: 5,080

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Warning [Pages Of Foreign References:]

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PTOL85b INFO

SERIAL NUMBER      FILING DATE

09/165,513      10/02/98

ASSIGNEE DATA PRESENT      DATE FEE PAID

Yes      01/29/03

EMAIL ADDRESS

ATTORNEYS

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Firm      Townsend and Townsend and Crew LLP

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City:      State: Country:

San Francisco      CA

Text:

REFERENCES (Page 7) SERIAL NUMBER: 09/165,513

FORM 1449

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<http://www.prnewswire.com> (Feb. 19, 2000).

\*\*\*\*\* End of edited forms \*\*\*\*\*

CHECK LIST

Rule 47    Continuing Data    PCT    Disclaimer

No           Yes           No           No

Microfiche Appendix    CPA tag

No                          No

Foreign Priority Claimed: No

Acknowledged: No

State Code: MN    Country Code:

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JACKET

<u>SERIAL NUMBER</u>	<u>FILING DATE</u>	<u>CLASS</u>	<u>SUBCLASS</u>	<u>GAU</u>
09/165,513	10/02/98	428	408	1773

FOREIGN PRIORITY

Country    Document Number    Date

DISCLAIMER

/ /

TITLE

Recording media having protective overcoats of highly tetrahedral amorphous carbon and methods for their production

MICROFICHE APPENDIX

ASSISTANT EXAMINER:

First:                Middle:                Last:

PRIMARY EXAMINER:

First:                Middle:                Last:

Stevan                   A.                   Resan

CLAIMS ALLOWED  
Total    Print

24            1

DRAWINGS  
Sheets    Figures    Print

12            20            Y

BLUE SLIP INFORMATION

<u>SERIAL NUMBER</u>	<u>CLASS</u>	<u>SUBCLASS</u>	<u>GAU</u>
09/165,513	428	408	1773

<u>INDEP. CLAIMS</u>	<u>TOTAL CLAIMS</u>
1,21,23,24	24

BLUE SLIP (Page 1)

INTERNATIONAL CLASSIFICATION  
Class    SubClass

G11B        5/72

CROSS-REFERENCES  
Class    SubClass

428        694 TC

TERM EXTENSION

0

FIELD OF SEARCH

Class    SubClass

428        408;694 TC

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Firm      Townsend and Townsend and Crew LLP

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ASSIGNEES

Code:      Firm/First:      Middle:      Last:

02      United Module Corporation, Inc.

City:      State: Country:

San Francisco      CA

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City: Palo Alto  
State: CA    ZIP Code:    Country:      Foreign ZIP:

PCT INFO

CONTINUING DATA (Page 1)

<u>LINE</u>	<u>CODE</u>	<u>SERIAL NUMBER</u>	<u>FILING DATE</u>	<u>STATUS</u>	<u>DOCUMENT NO.</u>	<u>ISSUE DATE</u>
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